Model Based, Data Driven Identification and Control for Developing Intelligent and Smart Processes and Systems

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Message from the Guest Editors

This Special Issue "Model Based, Data Driven Identification and Control for Developing Intelligent and Smart Processes and Systems" will publish very high-quality, novel multi-disciplinary research results on identification and control on the identified application areas. The papers submitted to this Special Issue must include sufficient mathematical and scientific justification to validate the results and a mere explanation of the proof of concept of the technology will not be accepted for review. The word control and identification included in the scope signifies the development of new methods for the complexities included in the processes and systems. The following potential topics are welcome for this Special Issue, but are not limited to:

- Power and Energy Systems
- Bio-Processes and Systems
- Robotics and Manufacturing Processes and Systems

Special Issue

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Message from the Editor-in-Chief

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